# FORM PTO-1449

# O LISE OF PATENTS AND PUBLICATIONS FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT

MAR 0 3 2006 (use several sheets if necessary)

Atty. Docket No.	L3799-01	
Serial No.		
	10/547,443	
Applicant	Couturier	
Filing Date	August 26, 2005	
Group Art Unit	Not yet assigned	
Examiner	Not yet assigned	

### U.S. PATENT DOCUMENTS

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB	FILING DATE IF APPROPRIATE
/0.0./	A1	4,277,431	7/7/1981	Peller	264	148	5/21/1979
1	A2	4,462,502	7/31/1984	Luenser et al.	215	329	7/22/1982
	A3	4,518,336	5/21/1985	Alieri	425	110	3/23/1984
	A4	4,870,128	9/26/1989	Couturier et al.	524	556	3/18/1989
	A5	5,045,594	9/3/1991	Samuel et al.	525	57	6/23/1989
	A6	5,104,710	4/14/1992	Knight	428	66	3/20/1989
	A7	5,186,991	2/16/1993	Samuel et al.	428	35.8	6/7/1991
1	A8	5,929,128	7/271999	Whetten et al.	521	85	8/8/1996
V	A9	6,399,170	6/4/2002	Hock et al.	428	36.6	12/24/1997

#### FOREIGN PATENT DOCUMENTS

EXAMINER			DOCUMENT	DATE	COUNTRY	ENGLISH TRANSLATION	
INITIA			NUMBER	DATE	COUNTRY	YES	NO
/	0.0./	B1	0073334	11/19/87	EP	Y	
-		B2	0129309	8/3/1988	EP -	Υ	-
		В3	0207385	9/16/1992	EP	Y	
		B4	0331495	9/6/1986	EP	Y	
		B5	0478109	12/17/1995	EP	Y	
		В6	0488491	1/3/1996	EP	Y	
		B7	0599356	12/20/1995	EP	· Y	
		B8	0646158	10/14/1998	EP	Y	
		B9	01002763	7/27/1990	JP	Y(Abstract only)	
		B10	2000-008495	1/11/2000	JP	Y(Abstract only)	
		B11	2000266018	3/8/2002	JP	Y(Abstract only)	
		B12	2002-191166	7/5/2002	JP	Y(Abstract only)	
		B13	01/062837	8/30/2001	wo	Y	
$\neg$		B14	02/36672	5/10/2002	wo	Y	

# OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)

EXAMINER INITIAL						
/0.0./	C1	Freeman, Silicones, "An Introduction To Their Chemistry And Applications", published for the Plastics Institue, 1962				
EXAMINER		/Olatunde Ojurongbe/	DATE CONSIDERED	03/07/2008		

EXAMINER: Initial reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.